



Subt. For, PTO-1449		Docket Number 107262.184 US2	Application Number 10/698,822
INFORMATION DISCLOSURE IN AN APPLICATION (Use several sheets if necessary)		Applicant Allen et al.	
		Filing Date October 30, 2003	Group Art Unit 2184
Sheet 1	OF 1		

U.S. Patent Documents						
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
BT	4,692,877	09/08/1987	Byerly et al.	364	514	06/27/1986
	4,796,038	01/03/1989	Allen et al.	354	4	03/28/1988
	4,797,698	01/10/1989	Allen et al.	354	4	09/21/1987
	5,018,807	05/28/1991	Shirota	350	6.8	12/18/1989
	5,235,438	08/10/1993	Sasada	358	481	08/14/1991
	5,386,221	01/31/1995	Allen et al.	346	108	11/02/1992
	5,594,556	01/14/1997	Vronsky et al.	358	482	03/21/1994
BT	5,635,976	06/03/1997	Thuren et al.	347	253	01/05/1995

Foreign Patent Documents							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
BT	WO 00/57629	09/28/2000					

Other Documents (Including Author, Title, Date Pertinent Pages, Etc.)		
BT	A1	Allen, Paul C. "Laser Scanning for Semiconductor Mask Pattern Generation," Proceedings of the IEEE, Vol. 90, No. 10, pp. 1653-1669 (2002)

EXAMINER / Brandi N. Thomas /	DATE CONSIDERED 08/18/2006
EXAMINER: Initial if citation is considered, whether or not citation is in conformance with MPEP § 609: Draw Line through citation if not conformance and not considered. Include copy with next communication to applicant.	